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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/747,824	12/29/2003	Daniel C. Diana	INTEL16	6455
6980 7	590 06/16/2005		EXAMINER	
TROUTMAN SANDERS LLP			DANG, TRUNG Q	
BANK OF AM	IERICA PLAZA, SUIT	E 5200		
600 PEACHTREE STREET, NE			ART UNIT	PAPER NUMBER
	GA 30308-2216		2823	

DATE MAILED: 06/16/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)	
	10/747,824	DIANA ET AL.	
Office Action Summary	Examiner	Art Unit	
	Trung Dang	2823	
The MAILING DATE of this commu Period for Reply	nication appears on the cover shee	t with the correspondence address -	-
A SHORTENED STATUTORY PERIOD  THE MAILING DATE OF THIS COMMUN  - Extensions of time may be available under the provisior after SIX (6) MONTHS from the mailing date of this com  - If the period for reply specified above is less than thirty If NO period for reply is specified above, the maximum of Failure to reply within the set or extended period for reply reply received by the Office later than three months earned patent term adjustment. See 37 CFR 1.704(b).	NICATION. as of 37 CFR 1.136(a). In no event, however, ma imunication. (30) days, a reply within the statutory minimum o statutory period will apply and will expire SIX (6) I by will, by statute, cause the application to becom	y a reply be timely filed f thirty (30) days will be considered timely. MONTHS from the mailing date of this communica e ABANDONED (35 U.S.C. § 133).	ation.
Status	,		
1) Responsive to communication(s) fi	led on <u>07 <i>April</i> 2005</u> .		
2a)⊠ This action is FINAL.	2b)☐ This action is non-final.		
3) Since this application is in condition closed in accordance with the practice.	· · · · · · · · · · · · · · · · · · ·		s is
Disposition of Claims			
4) ⊠ Claim(s) <u>1-25</u> is/are pending in the 4a) Of the above claim(s) is/ 5) ⊠ Claim(s) <u>1-9 and 22-25</u> is/are allow 6) ⊠ Claim(s) <u>10-15 and 18</u> is/are reject 7) ⊠ Claim(s) <u>16-17, 19-21</u> is/are object 8) □ Claim(s) are subject to restr	are withdrawn from consideration. red. ed. ed to.		
Application Papers			
9) The specification is objected to by t 10) The drawing(s) filed on is/arc Applicant may not request that any obj	e: a) accepted or b) objected ection to the drawing(s) be held in about	eyance. See 37 CFR 1.85(a).	M/ II
Replacement drawing sheet(s) includir 11) The oath or declaration is objected			
Priority under 35 U.S.C. § 119			
·	y documents have been received. y documents have been received s of the priority documents have be ional Bureau (PCT Rule 17.2(a)).	in Application No een received in this National Stage	
Attachment(s)			
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Notice of Draftsperson's Patent Drawing Review</li> <li>Information Disclosure Statement(s) (PTO-1449 Paper No(s)/Mail Date</li> </ol>	(PTO-948) Paper	ew Summary (PTO-413) No(s)/Mail Date of Informal Patent Application (PTO-152)	

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#### **DETAILED ACTION**

### Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - . (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 13-15, 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Johnson et al. (US 2002/0197844) in view of Gudesen (US 2003/0107067).

The rejection is maintained as of record and repeated herein.

With reference to Figs. 9-10, Johnson teaches a ferroelectric die, comprising:

a silicon (Si) substrate 10;

an oxide thermal insulation layer 20 on top of the Si substrate;

a first metal layer 22, 28 on top of the oxide layer;

a ferroelectric layer 30' on top of the first metal layer (Fig. 9 and para.[0044]);

an interlevel dielectric (ILD) layer 36' on top of the ferroelectric layer;

a second metal layer 40 having on top of the ILD layer; and

a via metal 99 plug passing through the ILD layer and the ferroelectric

layer to electrically connect the first metal layer 22, 28 to the second metal layer

40.

Note that the metal layer 99 is broadly interpreted as via metal plug because it is formed in the via.

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Johnson differs from the claims in that while Johnson discloses layer 30' is of ferroelectric material, the claims call for a ferroelectric polymer.

Gudesen teaches the advantages of ferroelectric polymer materials, for example, their dielectric properties allow their function as electrically insulating barrier materials as well as the possibility of applying them in global layers of extreme thickness down to few nanometers (para. [0032]).

It would have been obvious to one of ordinary skill in the art to modify the teaching of Johnson by selecting the ferroelectric polymer material for the ferroelectric layer 30' as suggested by Gudesen because of the benefits mentioned above.

As for claims 14 and 15, Fig. 10 depicts metal layer 99 has a step and the portion adjacent to the step is below the surface of the ILD 36'.

As for claim 18, metal layer 99 has a portion that is coplanar with the IDL layer 36'.

## Allowable Subject Matter

2. Claims 16-17 and 19-21 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

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3. Claims 1-9, 22-25 are allowed.

4. The following is an examiner's statement of reasons for allowance:

Independent claim 1 and its dependent claims are allowed over prior of record because the prior art of record does not teach or suggest the claimed step regarding an electroless plating process.

Independent claim 22 and its dependent claims are allowed over prior of record because the prior art of record does not teach or suggest the claimed structure regarding a plurality of metallization layers stacked on an oxide layer, wherein each metallization layer comprises elements as recited in the claim.

### Response to Arguments

5. Applicant's arguments filed 4/7/05 have been fully considered but they are not persuasive.

At the bottom of page 8of the Remarks, applicants argue that the copper diffusion barrier layer 99 do not provide an electrical contact between the thin metal layer and the copper plug. The Examiner disagrees. As shown in Fig. 10, because layers 22, 99 and 40 are made of metallic materials therefore the diffusion barrier layer 99 clearly provides electrical connection between copper plug 40 and metal layer 22. Applicants further stated that "the copper diffusion barrier layer is only part of the via plug". This is exactly what the Examiner interpreted metal layer 99 as via metal plug in

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the rejection since the claim 13 does not specify the claimed via metal plug is a part or a whole of the plug. In page 9, applicants argue that Johnson does not include a second metal layer on the of the ILD layer but rather the second metal layer lies entirely within the trench or via. In response, it is noted that paragraph [0070] discloses that prior to the CMP process copper layer 40 lies outside the trench. Thus, the intermediate structure (i.e. before the CMP) copper layer 40 lies on top of the ILD layer 36, which rendering the claimed structure anticipated by the intermediate structure of Johnson.

#### **Conclusion**

6. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

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7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Trung Dang whose telephone number is 571-272-1857. The examiner can normally be reached on Mon-Friday 9:30am-6:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Trung Dang Primary Examiner Art Unit 2823

6/12/05